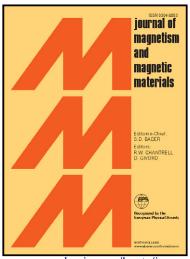
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Giant tunneling electroresistance in ferroelectric-

gated silicene junction

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Abstract

The electroresistance in silicene-based normal/ferroelectric-gated/normal

junction is investigated. The energy gap in silicene can be tuned by electric field. The

spontaneous electric polarization in ferroelectric (FE) can be switched by external

electric field. Due to the combination of these properties, we find that the studied

junction may generate tunneling electroresistance (TER) exceeding 10⁹%. The

conductance ratio between ON and OFF-states, Gon /Goff, is found to be larger than

10⁷, enhanced by increasing the thickness of the barrier or increasing the magnitude

of electric polarization in the FE-layer. The giant TER effect is directly related to the

buckled lattice and the presence of spin orbit interaction in silicene. This work reveals

the potential of silicene as a good material for application of ferroelectric random-

access memory.

Keywords: Silicene; ferroelectric; electroresistance; ferroelectric RAM;

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